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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/718,789	11/24/2003	Kazunori Hagimoto	SUG-176-USAP	1591
28892 SNIDER & AS	7590 09/28/200 SOCIATES	EXAMINER		
P. O. BOX 276	- -	WEISS, HOWARD		
WASHINGTO	N, DC 20038-7613		ART UNIT	PAPER NUMBER
		2814		
			MAIL DATE	DELIVERY MODE
			09/28/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Applicat	ion No.	Applicant(s)			
Office Action Summary		10/718,	789	HAGIMOTO ET AL			
		Examine	er	Art Unit			
		Howard	Weiss	2814			
The MAILING Period for Reply	DATE of this communi	cation appears on ti	ne cover sheet with the	correspondence add	dress		
A SHORTENED ST WHICHEVER IS LC - Extensions of time may b after SIX (6) MONTHS fr - If NO period for reply is s - Failure to reply within the Any reply received by the	ATUTORY PERIOD FOR MIGER, FROM THE MIDER AVAILABLE AVAILABLE AND THE MIDER AVAILABLE AT A COMMENT OF THE MIDER AND	AILING DATE OF T of 37 CFR 1.136(a). In no e unication. tutory period will apply and will, by statute, cause the ap	THIS COMMUNICATIOn Event, however, may a reply be to will expire SIX (6) MONTHS from Expirication to become ABANDONICATION TO THE COMMUNICATION THE COMMUNICATION THE COMMUNICATION THE COMMUNICATION	N. imely filed in the mailing date of this col ED (35 U.S.C. § 133).			
Status							
 Responsive to communication(s) filed on <u>06 April 2007</u>. This action is FINAL. 2b) This action is non-final. Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i>, 1935 C.D. 11, 453 O.G. 213. 							
Disposition of Claims							
4a) Of the abo 5) ☐ Claim(s) 6) ☑ Claim(s) <u>33-3</u> 7) ☐ Claim(s) 8) ☐ Claim(s) Application Papers 9) ☐ The specification		tion and/or election	requirement.	Examiner.			
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.0	C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 							
	s Patent Drawing Review (P Statement(s) (PTO/SB/08)	TO-948)	4) Interview Summar Paper No(s)/Mail [5] Notice of Informal 6) Other:	Date			

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Attorney's Docket Number: SUG-176-USAP

Filing Date: 11/24/03

Continuing Data: RCE established 11/15/2006

Claimed Foreign Priority Date: 11/28/2002, 12/25/2002, 1/31/2003, 8/29/2003

Applicant(s): Hagimoto et al. (Noto)

Examiner: Howard Weiss

Claim Rejections - 35 USC § 103

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 33 to 38 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yasutimi et al. (JP 2001-339100), Carter-Coman et al. (U.S. Patent No. 6,222,207), Burt (U.S. Patent No. 4,574,470) and Murasato et al. (U.S. Patent No. 5,744,829).

Yasutimi et al. show most aspects of the instant invention (e.g. Figure 2) including:

- A compound semiconductor layer 4 including a light-emitting layer consisting of N-type AlGaInP cladding layer 41, an AlGaInP active layer 42 and a P-type AlGaInP cladding layer 43 and a light extraction surface 44 and sensitive to the wavelength ranges listed
- > A silicon device substrate 2 bonded to said compound semiconductor layer
- ➤ A multilayered metal reflective layer 3 including an Au-based main metal layer 31 and another metal based 32 (i.e. Al) layer interposed between the Au-based layer and the compound semiconductor layer

Yasutimi et al. do not show the metal reflective layer being Ag based, an Ag-based contact layer as claimed, a Au/Sb or Au/Sn substrate side metal contact layer and a

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silicon-diffusion-blocking layer of the composition claimed and the layers in the light-emitting layer to be explicitly composed of $(Al_xGa_{1-x})_yIn_{1-y}P$ where $0 \le x \le 1$ and $0 \le y \le 1$.

Carter-Coman et al. teach (e.g. Figures 2) that a metal reflective layer **34** can be either Al- or Ag-based (Column 5 Lines 25 to 30) therefore establishing their equivalence, a contact layer **32** and a silicon-diffusion-blocking layer **36** made of a conductive material with Ti or Ni as a major component (e.g. NiV) and a substrate side AuSn layer **38** to produce an light emitting device with high reflectivity after subjected to high temperatures (Column 2 Lines 23 to 34). It would have been obvious to a person of ordinary skill in the art at the time of invention to make a metal reflective layer Ag-based, a contact layer, a silicon-diffusion-blocking layer and a substrate side AuSn layer as taught by Carter-Coman et al. in the device of Yasutimi et al. to produce an light emitting device with high reflectivity after subjected to high temperatures.

Burt teaches (e.g. Column 6 Lines 41 to 47) that NiV inherently blocks silicon diffusion. The express, implicit, and inherent disclosures of a prior art reference may be relied upon in the rejection of claims under 35 U.S.C. 102 or 103. "The inherent teaching of prior art reference, a question of fact, arises both in the context of anticipation and obviousness." *In re Napier, 55 F.3d 610, 613, 34 USPQ2d 1782, 1784 (Fed. Cir.1995)* (affirmed a 35 U.S.C. 103 rejection based in part on inherent disclosure in one of the references). See also *In re Grasselli, 713 F.2d 731, 739, 218 USPQ 769, 775 (Fed.Cir. 1983)*.

Murasato et al. teach (e.g. Figure 1 and Column 3 Lines 55 to 63 and Column) to use double hetero-structure $(Al_xGa_{1-x})_yIn_{1-y}P$ where $0\le x\le 1$ and $0\le y\le 1$ in cladding layers **5,7** and active layer **6** to provide a high brightness, low operating voltage and high reliability device (Column 2 Lines 65 to 67). It would have been obvious to a person of ordinary skill in the art at the time of invention to use double hetero-structure $(Al_xGa_{1-x})_yIn_{1-y}P$ where $0\le x\le 1$ and $0\le y\le 1$ in cladding layers and active layer

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as taught by Murasato et al. in the device of Yasutimi et al. to provide a high brightness, low operating voltage and high reliability device.

Response to Arguments

3. Applicant's arguments filed 4/6/2007 have been fully considered but they are not persuasive. In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986). In this case, the reasons for combining the references are stated in the rejection above.

In reference to the rejection not addressing the problem confronted by the claimed invention (i.e. degradation of reflectivity), the mere fact that the references relied upon by the Examiner to evince an appreciation of the problem identified and solved by the instant invention is not, standing alone, conclusive evidence of the non-obviousness of the claimed subject matter. The references may suggest doing what an applicant has done even though those of ordinary skill in the art were ignorant of the existence of the problem. *In re Gershon*, 152 USPQ 602 (CCPA 1967).

In reference to the substrate-side contact metal, this feature is shown in Yasutomi et al. as layer **32** and was not explicitly pointed out in the previous Office Action. This has been corrected in the rejection above.

In view of these reasons and those set forth in the present office action, the rejections of the stated claims stand.

Conclusion

4. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP

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§ 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

- 5. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).
- 6. Papers related to this application may be submitted directly to Art Unit 2814 by facsimile transmission. The faxing of such papers must conform with the notice published in the Official Gazette, 1096 OG 30 (15 November 1989). The Art Unit 2814 Fax Center number is (571) 273-8300. The Art Unit 2814 Fax Center is to be used only for papers related to Art Unit 2814 applications.
- 7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Howard Weiss at (571) 272-1720 and between the hours of 7:00 AM to 3:00 PM (Eastern Standard Time) Monday through Friday or by e-mail via Howard-Weiss@uspto.gov. If attempts to reach the examiner by

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telephone are unsuccessful, the examiner's supervisor, Wael Fahmy, can be reached on **(571) 272-1705**.

8. The following list is the Examiner's field of search for the present Office Action:

Field of Search	Date	
U.S. Class / Subclass(es): 257/ 96, 98, E33.068	thru 9/27/2007	
Other Documentation: none		
Electronic Database(s): EAST	thru 9/27/2007	

HW/hw 28 September 2007 /Howard Weiss/ Primary Examiner Art Unit 2814